

Carbon-Quantum-Dot-Hybridized NiO_x Hole-Transport Layer Enables Efficient and Stable Planar p-i-n Perovskite Solar Cells with High Open-Circuit Voltage

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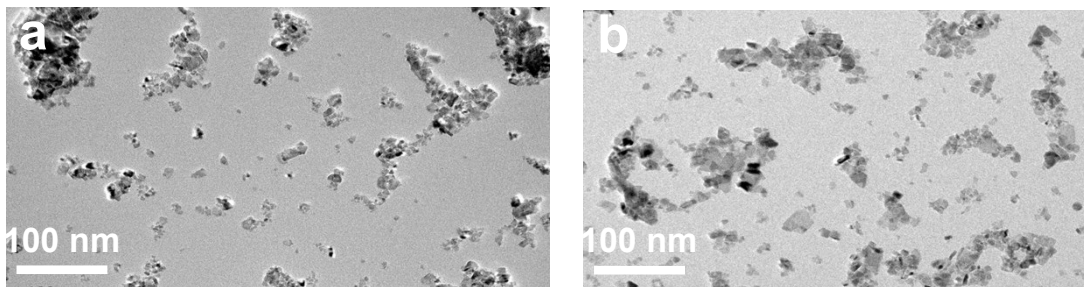


Figure S1. TEM images of a) the pristine NiO_x and b) CQDs-hybridized NiO_x dispersed in deionized water.

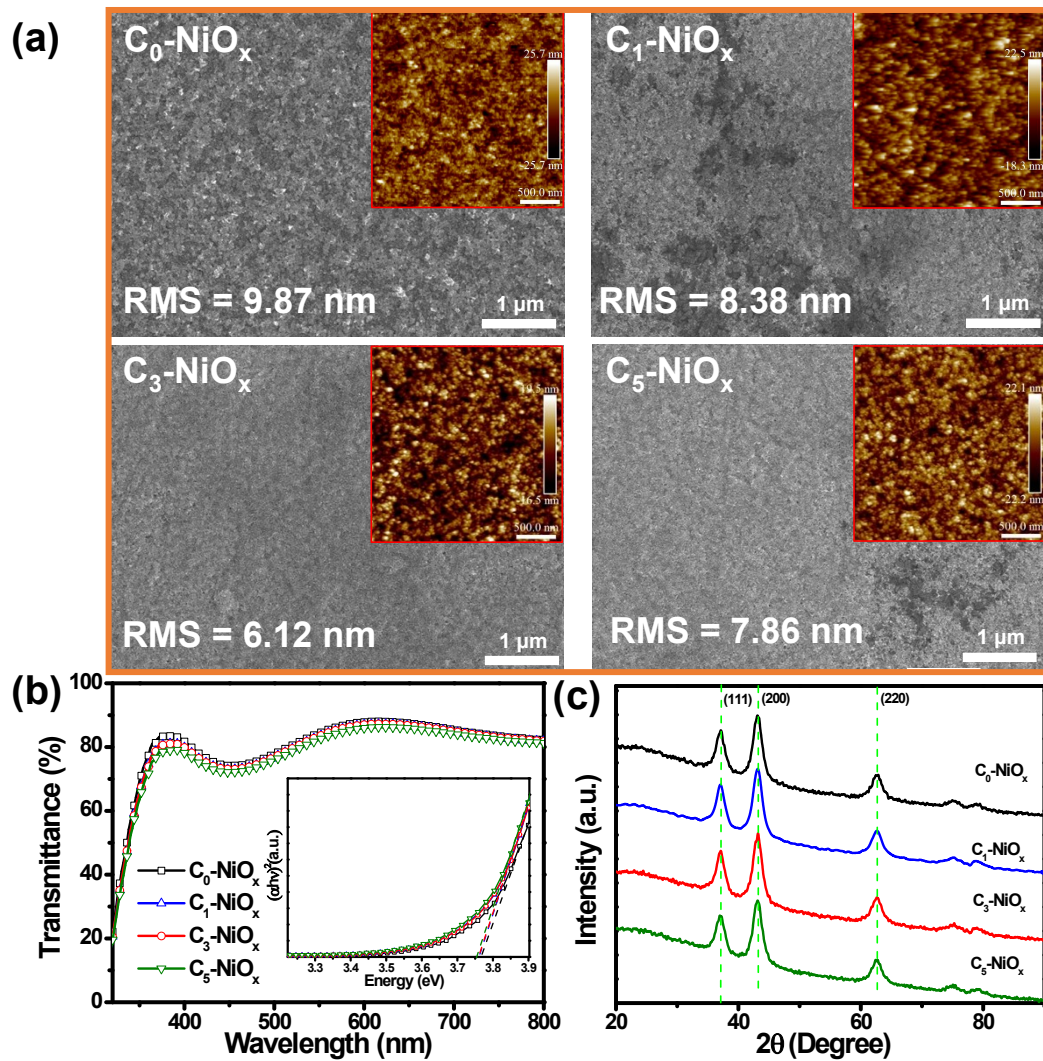


Figure S2. (a) FE-SEM and AFM (inset) images, (b) Optical transmittance (Inset: the corresponding Tauc plot of each film) and (c) X-ray diffraction spectra of the C₀-NiO_x, C₁-NiO_x, C₃-NiO_x and C₅-NiO_x films prepared on quartz substrates.

Table S1. Performance of the reported inverted planar MAPbI₃ PSCs based on NiO_x HTLs

Device configuration	V_{oc} (V)	J_{sc} (mA cm ⁻²)	FF	PCE	Method	HTL	Ref
ITO/Cu:NiO _x /MAPbI ₃ /PC ₆₁ BM/bis-C ₆₀ /Ag	1.11	19.01	0.73	15.40	sol-gel	Cu:NiO _x	[1]
ITO/Cu:NiO _x /MAPbI ₃ /C ₆₀ /bis-C ₆₀ /Ag	1.05	20.53	0.72	15.52	combustion	Cu: NiO _x	[2]
ITO/Cu:NiO _x /MAPbI ₃ /C ₆₀ /BCP/Ag	1.12	22.28	0.81	20.26	NP ink	Cu: NiO _x	[3]
ITO/Cu:NiO _x /Cysteine/MAPbI ₃ /PCBM/Bphen/Al	1.11	23.60	0.70	18.30	combustion	Cu: NiO _x	[4]
FTO/Cu:NiO _x /MAPbI ₃ /PCBM /Ag	1.06	20.79	0.67	14.88	DCMS	Cu: NiO _x	[5]
ITO/Ag:NiO _x /MAPbI ₃ /PC ₇₁ BM/BCP /Ag	1.08	19.70	0.80	16.86	sol-gel	Ag: NiO _x	[6]
ITO/Co:NiO _x /MAPbI ₃ /PCBM/PEI/Ag	1.05	22.30	0.79	18.60	combustion	Co: NiO _x	[7]
FTO/Zn:NiO _x /MAPbI ₃ /PCBM/BCP/Ag	1.10	22.80	0.78	19.6	sol-gel	Zn: NiO _x	[8]
FTO/LiNiO/MAPbI ₃ -xCl _x /PCBM/Ag	1.12	21.79	0.74	18.00	magnetron	Li: NiO _x	[9]
FTO/NiMgO _x /MAPbI ₃ /PCBM/ZnMgO/Al	1.08	21.30	0.80	18.50	sol-gel	NiMgO	[10]
FTO/ Sr:NiO _x /MAPbI ₃ /PCBM/AgAl	1.11	22.73	0.79	20.05	sol-gel	Sr:NiO _x	[11]
TO/Cs:NiO _x /MAPbI ₃ /PCBM/ZrAcac/Ag	1.12	21.77	0.79	19.35	sol-gel	Cs: NiO _x	[12]
ITO/Li, Ag:NiO _x /MAPbI ₃ /PCBM/BCP/Ag	1.13	21.29	0.80	19.24	sol-gel	Li,Ag: NiO _x	[13]
FTO/La:NiO _x /MAPbI ₃ /PCBM/BCP/Ag	1.01	21.02	0.73	15.46	NP ink	La: NiO _x	[14]
ITO/Fe:NiO _x /MAPbI ₃ /PCBM/BCP/Ag	1.08	19.10	0.84	17.40	spray coating	Fe: NiO _x	[15]
FTO/NiO _x /MAPbI ₃ /PCBM/Ag	1.03	17.42	0.71	12.70	sol-gel	NiO _x	[16]
ITO/NiO _x (F4-TCNQ)/MAPbI ₃ /PCBM/BCP/Ag	1.02	20.70	0.74	15.70	sol-gel	F4-TCNQ:NiO _x	[17]
FTO/S:NiO _x /MAPbI ₃ /PCBM/PPDIN6/Ag	1.10	23.28	0.80	20.43	spray coating	S: NiO _x	[18]
FTO/NiO _x /MAPbI ₃ /PCBM/Ag	1.01	18.30	0.81	14.95	EBPVD	NiO _x	[19]
FTO NiO _x /MAPbI ₃ /C ₆₀ /SnO ₂ NCs/Ag	1.12	21.8	0.77	18.80	sol-gel	NiO _x	[20]
ITO/NiO/MAPbI ₃ /PCBM/PDINO/Ag	1.11	20.57	0.76	17.50	NP ink	NiO _x	[21]

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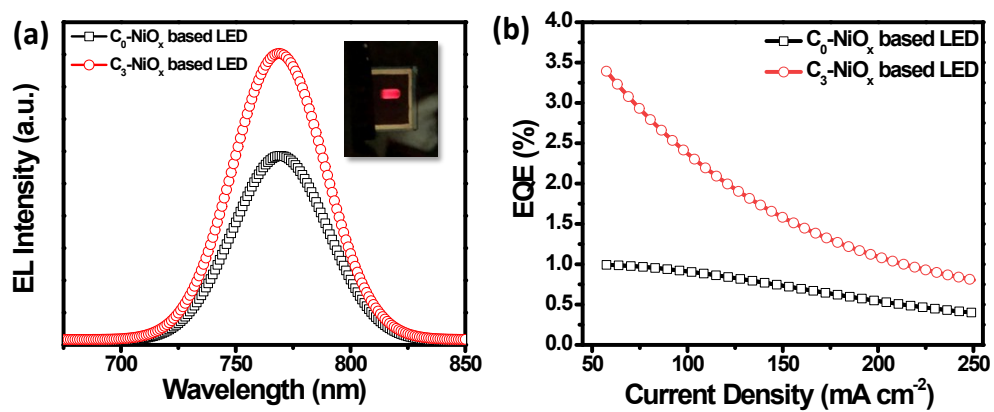


Figure S3. a) The electroluminescence spectra (EL) and b) EQE-current density curves for the best-performing C_0 -NiO_x and C_3 -NiO_x devices operating as LEDs (Insert: EL image of the C_3 -NiO_x device).

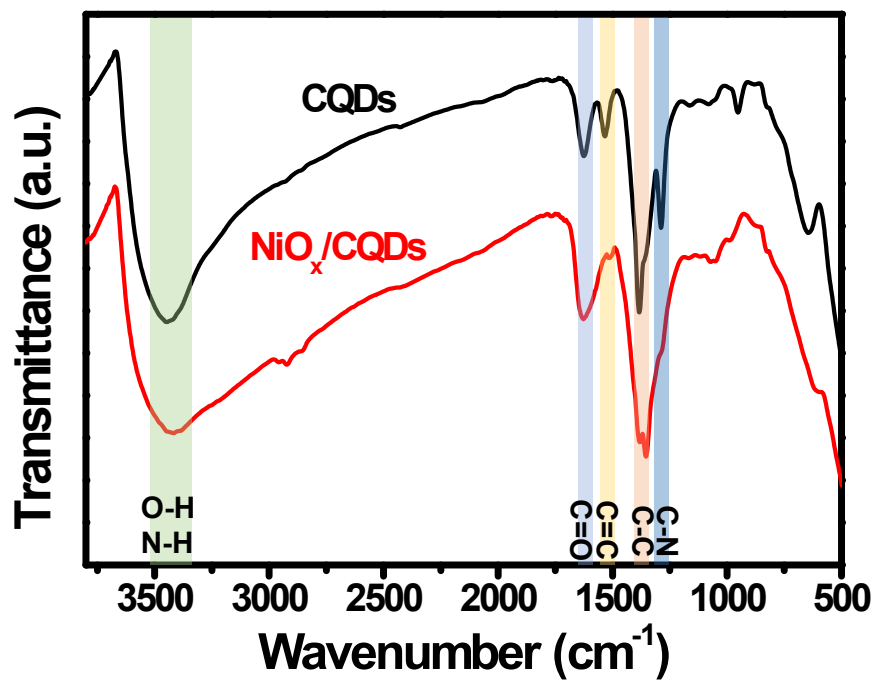


Figure S4. FT-IR spectra of the CQDs and CQDs-hybridized NiO_x films.

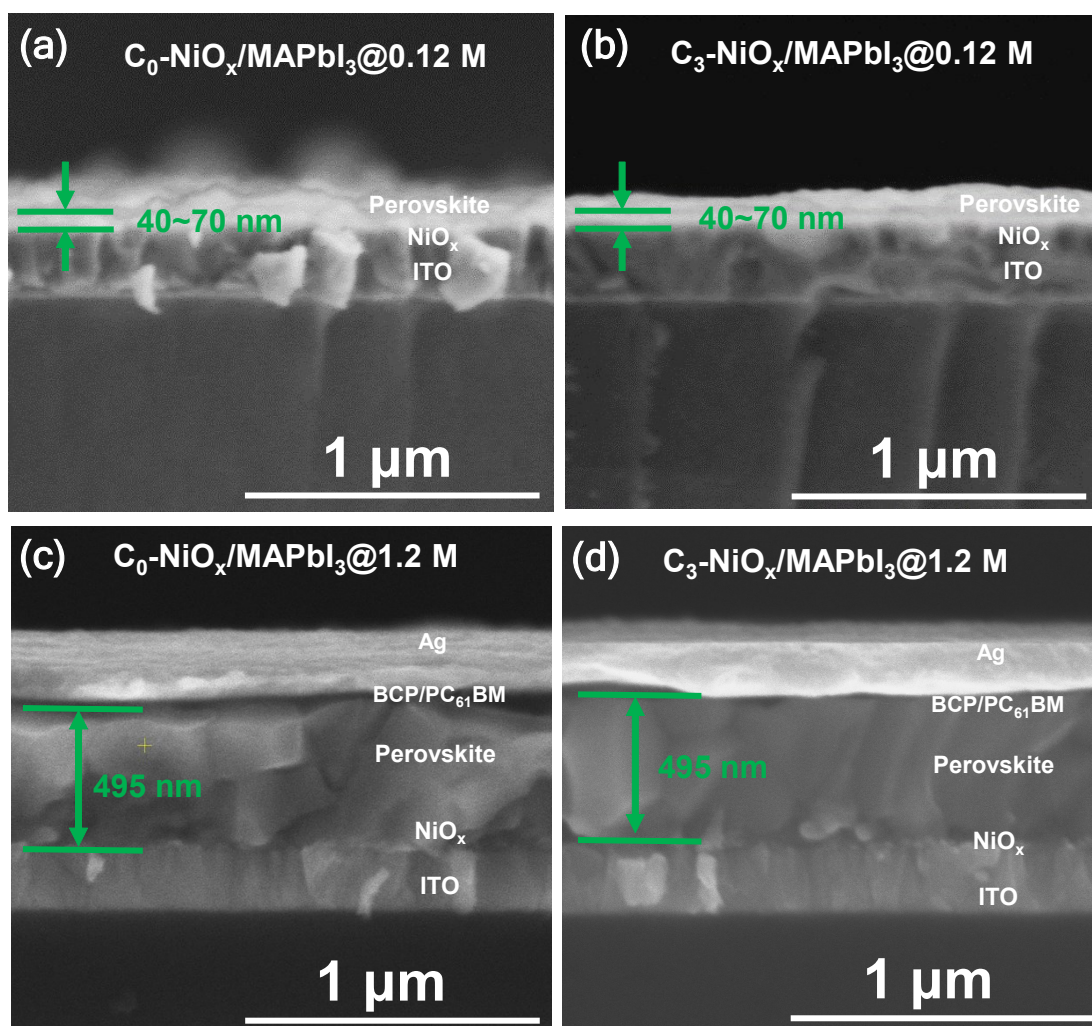


Figure S5. The cross-sectional SEM images of (a, b) thin perovskite films (casting from 0.12 M perovskite precursor solution) on C_0 -NiO_x and C_3 -NiO_x films, respectively, and (c, d) thick perovskite films (casting from 1.2 M perovskite precursor solution) on C_0 -NiO_x and C_3 -NiO_x films, respectively.

Table S2. XRD parameters of thin and thick perovskite films on C₀-NiO_x and C₃-NiO_x HTLs

Concentrations	Samples	FWHM of (110) (degree)	Intensity ratio of (110) to (310)
0.12 M	C ₀ -NiO _x	0.38	1.73
	C ₃ -NiO _x	0.27	8.31
1.20 M	C ₀ -NiO _x	0.17	3.78
	C ₃ -NiO _x	0.12	4.76

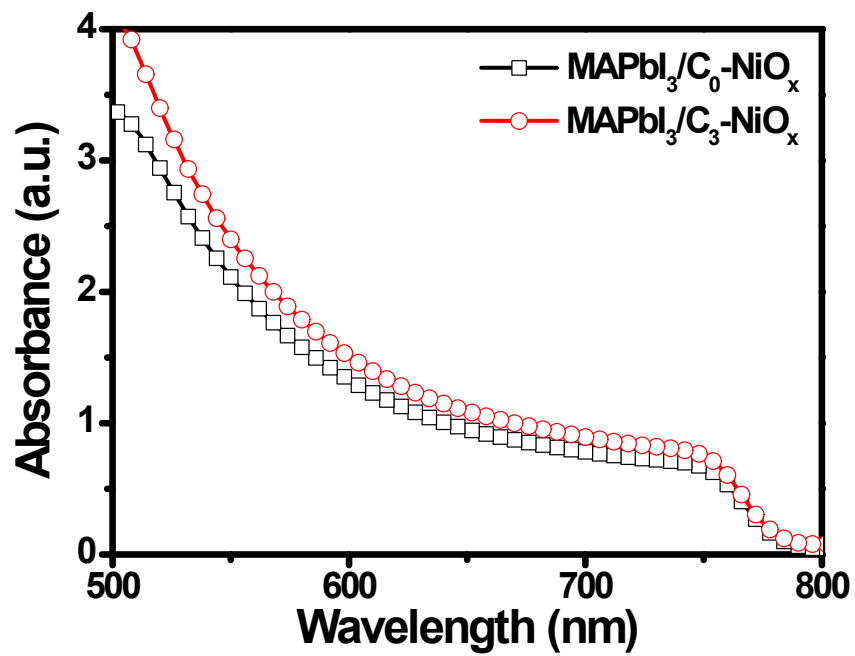


Figure S6. UV-vis absorption spectra of thick MAPbI₃ films deposited on the C₀-NiO_x and C₃-NiO_x films.

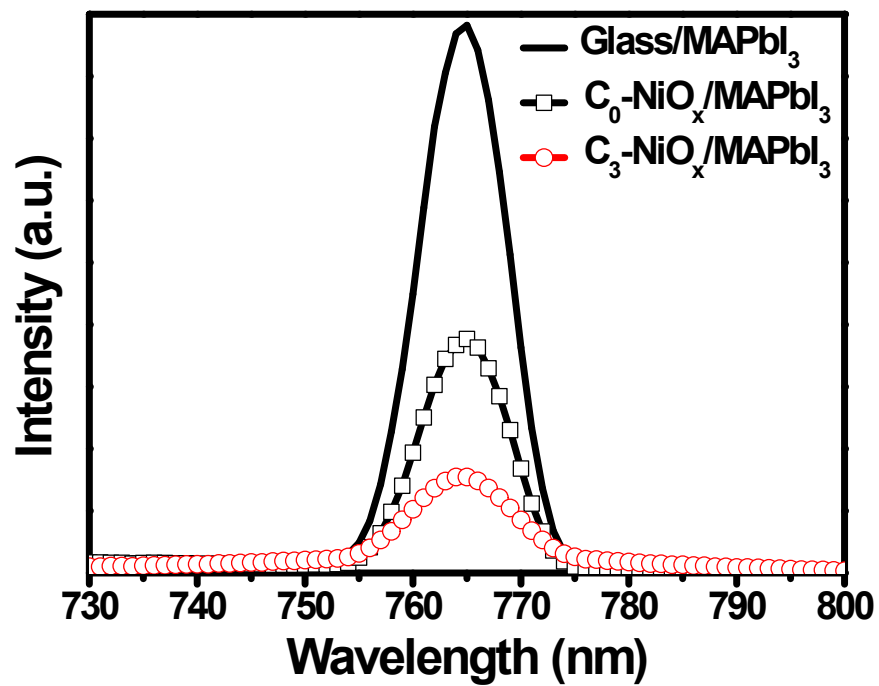


Figure S7. Steady-state PL spectra of MAPbI₃ perovskite films deposited on the glass, C₀-NiO_x and C₃-NiO_x films.